



US00D470551S

(12) **United States Design Patent** (10) **Patent No.:** **US D470,551 S**
Lin (45) **Date of Patent:** **** Feb. 18, 2003**

(54) **MASK**

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(**) **Term:** **14 Years**

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(51) **LOC (7) Cl.** **21-03**

(52) **U.S. Cl.** **D21/660; D21/622**

(58) **Field of Search** D21/622, 660,
D21/659; D2/741; D11/160, 136; 2/206,
173, 171, 202; 446/27

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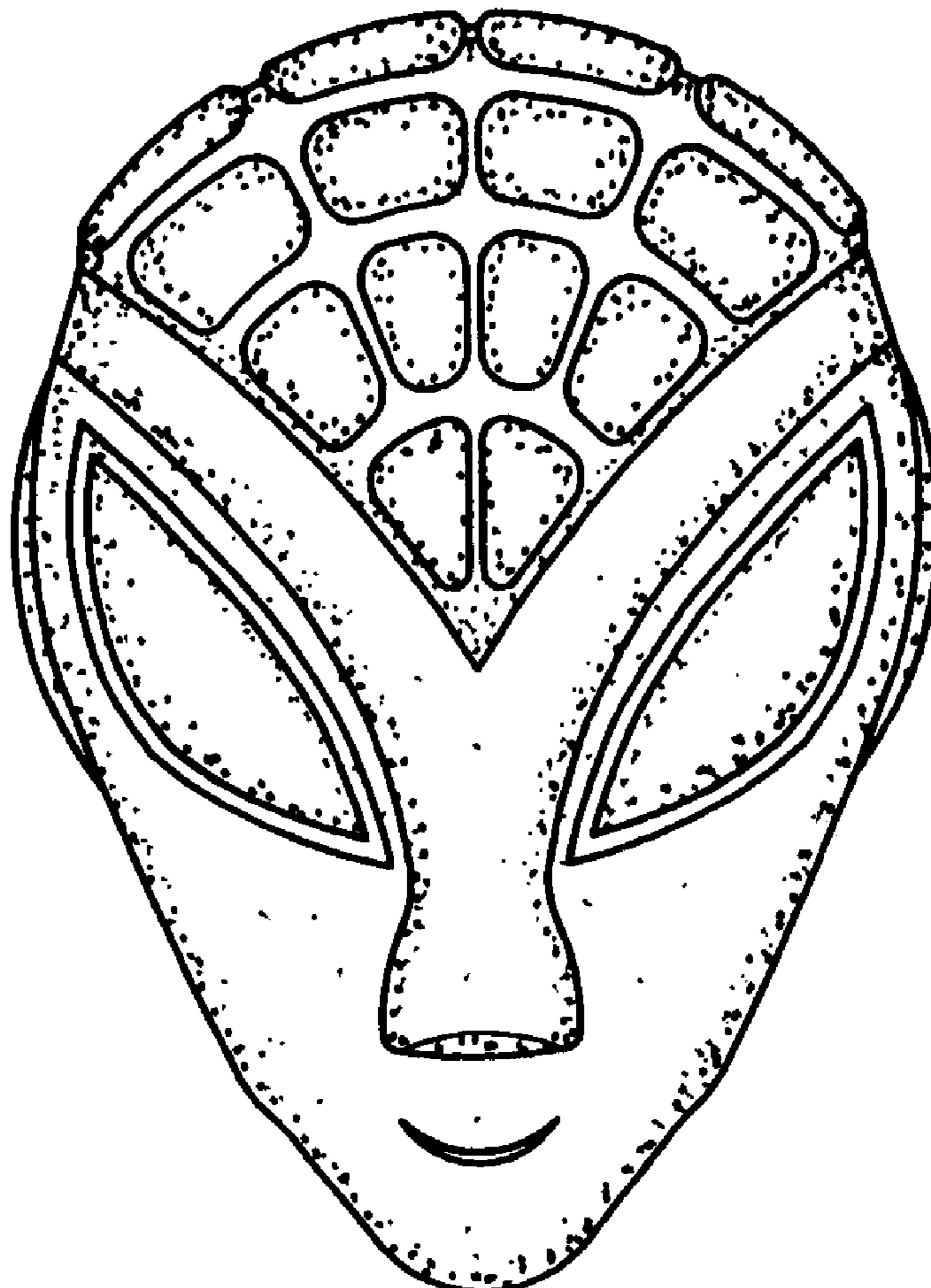
(57) **CLAIM**

The ornamental design for a mask, as shown and described.

DESCRIPTION

FIG. 1 is a perspective view of a mask showing my new design;
FIG. 2 is a side elevation as seen from the right side of FIG. 1;
FIG. 3 is a side elevation as seen from the left side of FIG. 1;
FIG. 4 is a front elevation thereof;
FIG. 5 is a rear elevation thereof;
FIG. 6 is a top plan view thereof; and,
FIG. 7 is a bottom plan view thereof.

1 Claim, 4 Drawing Sheets



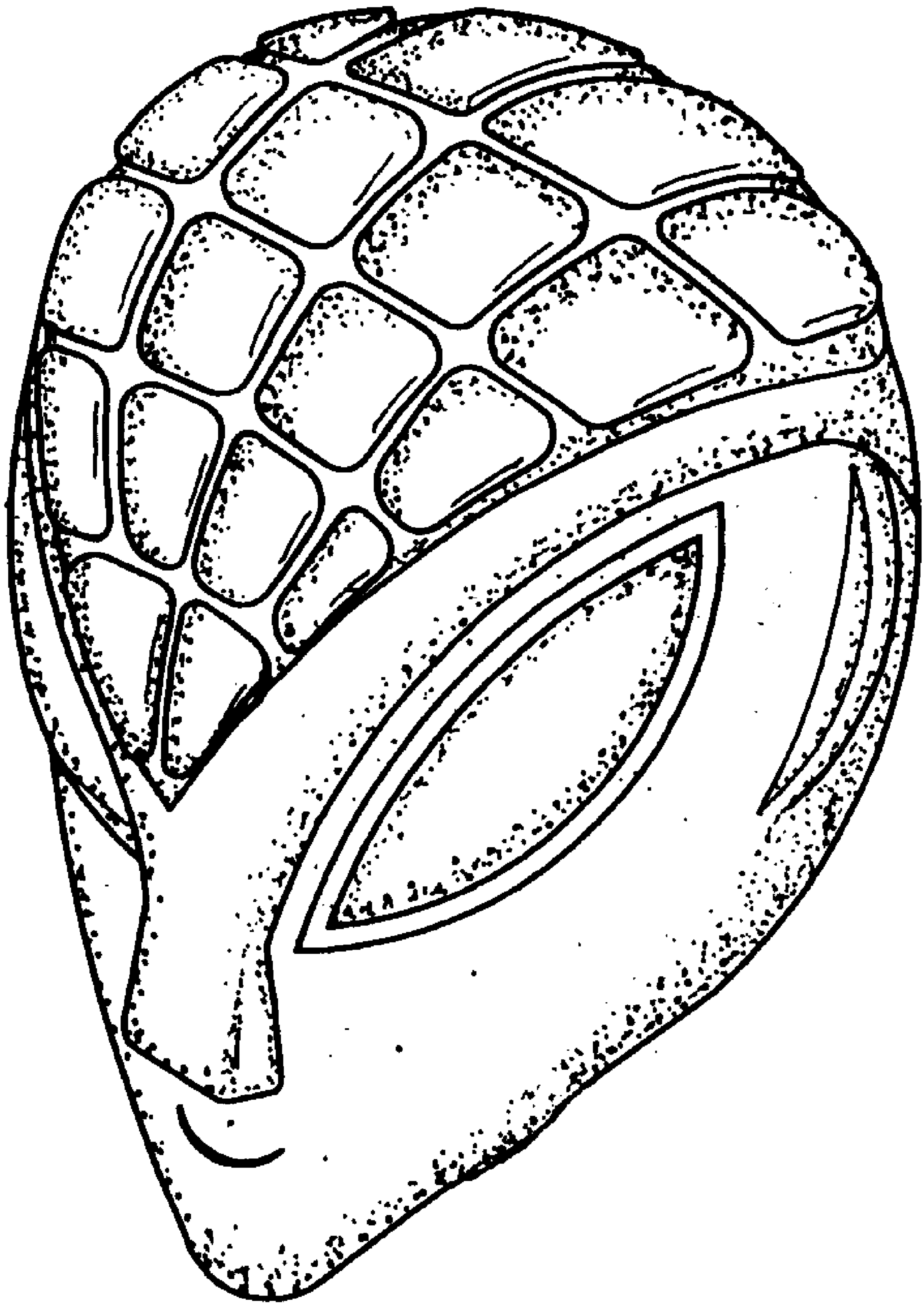


Fig. 1

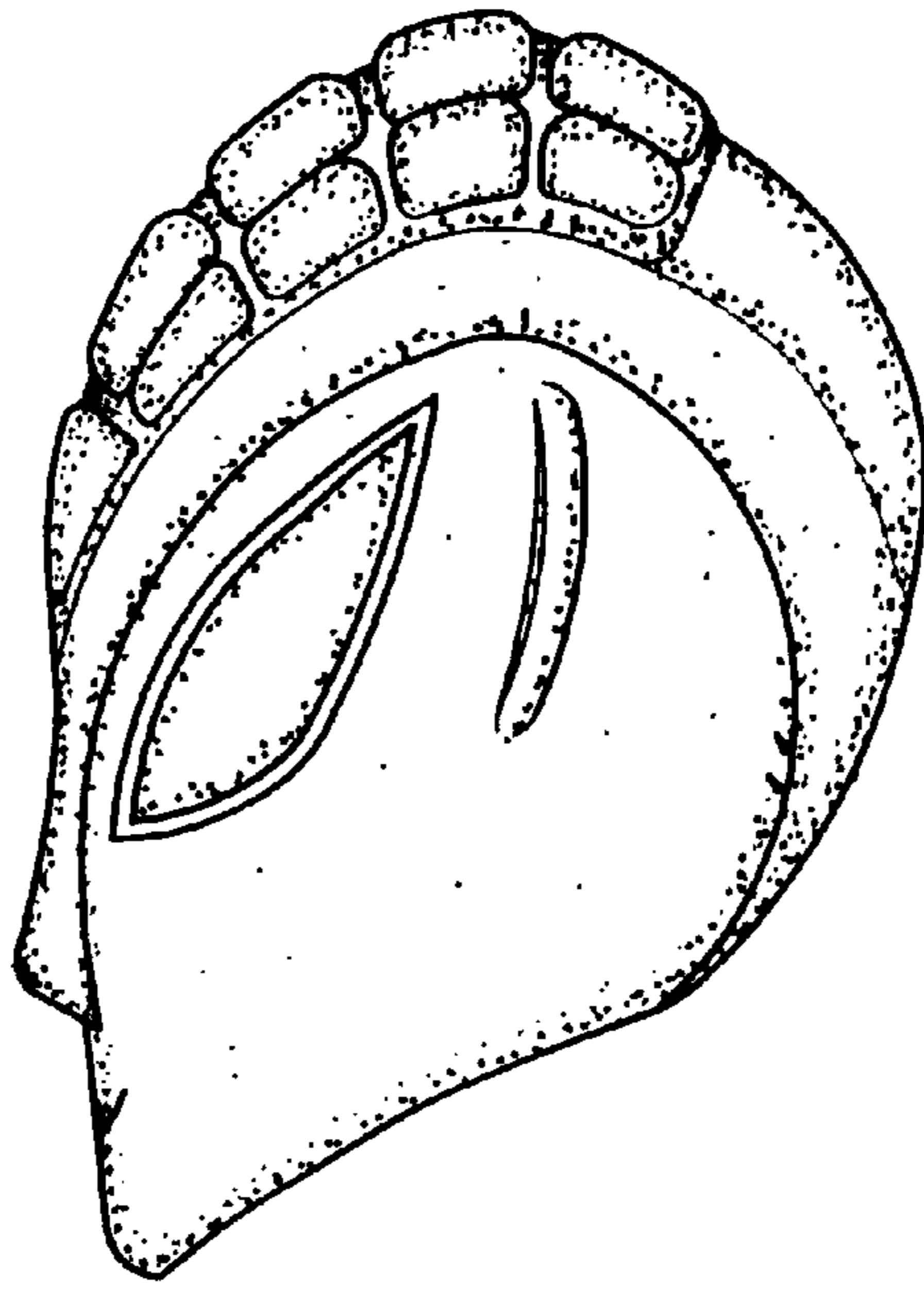


Fig.2

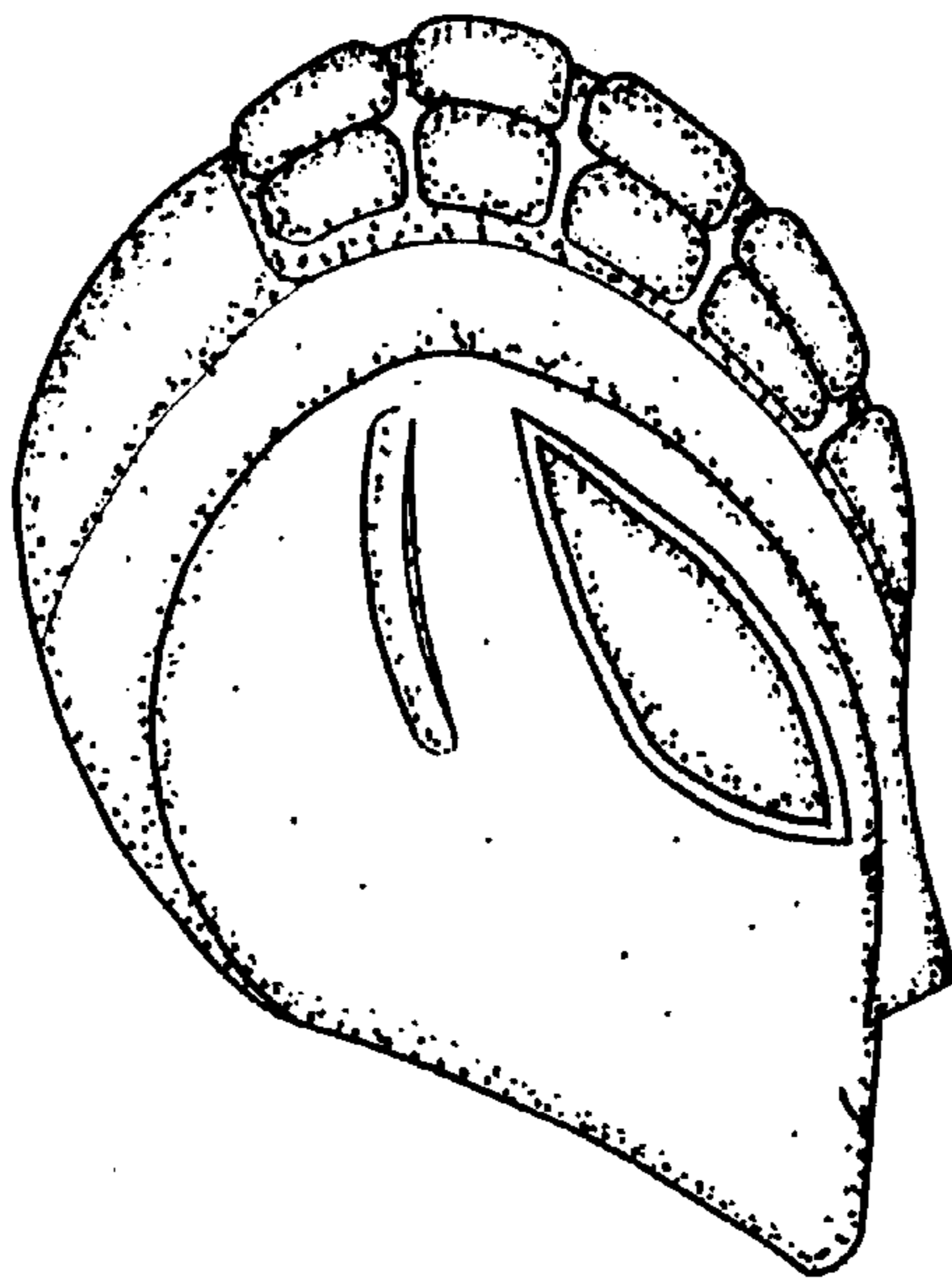


Fig.3

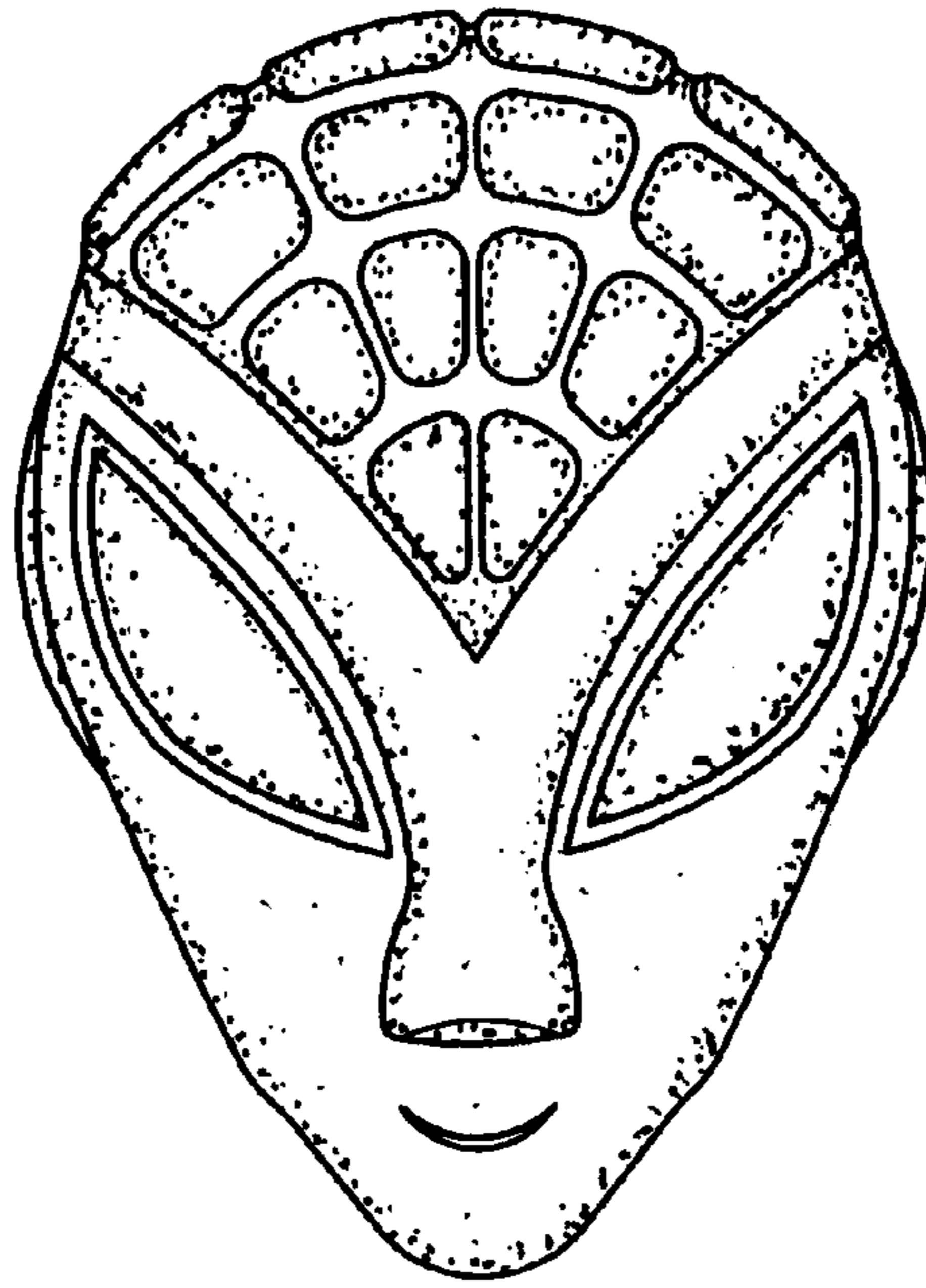


Fig.4

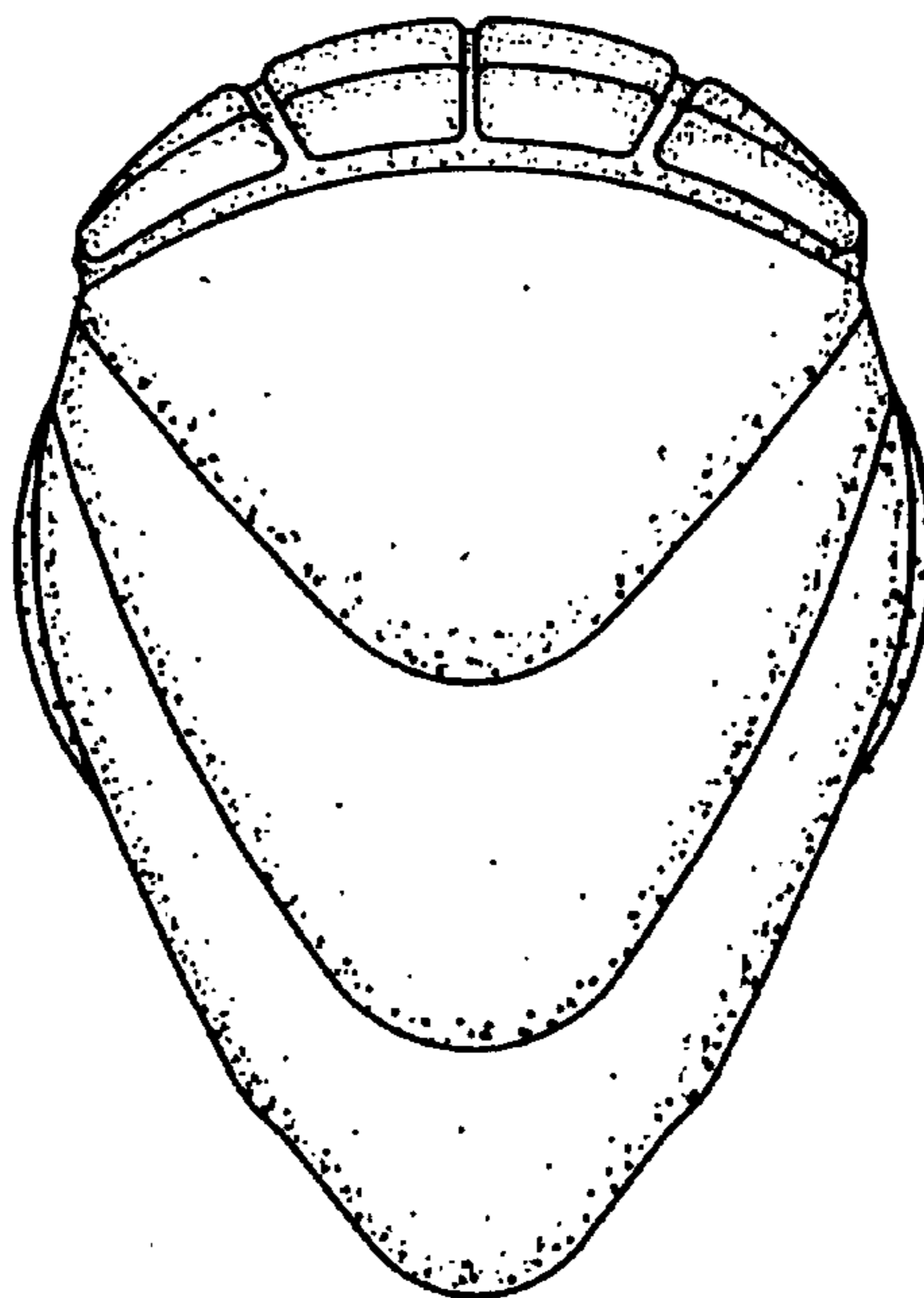


Fig.5

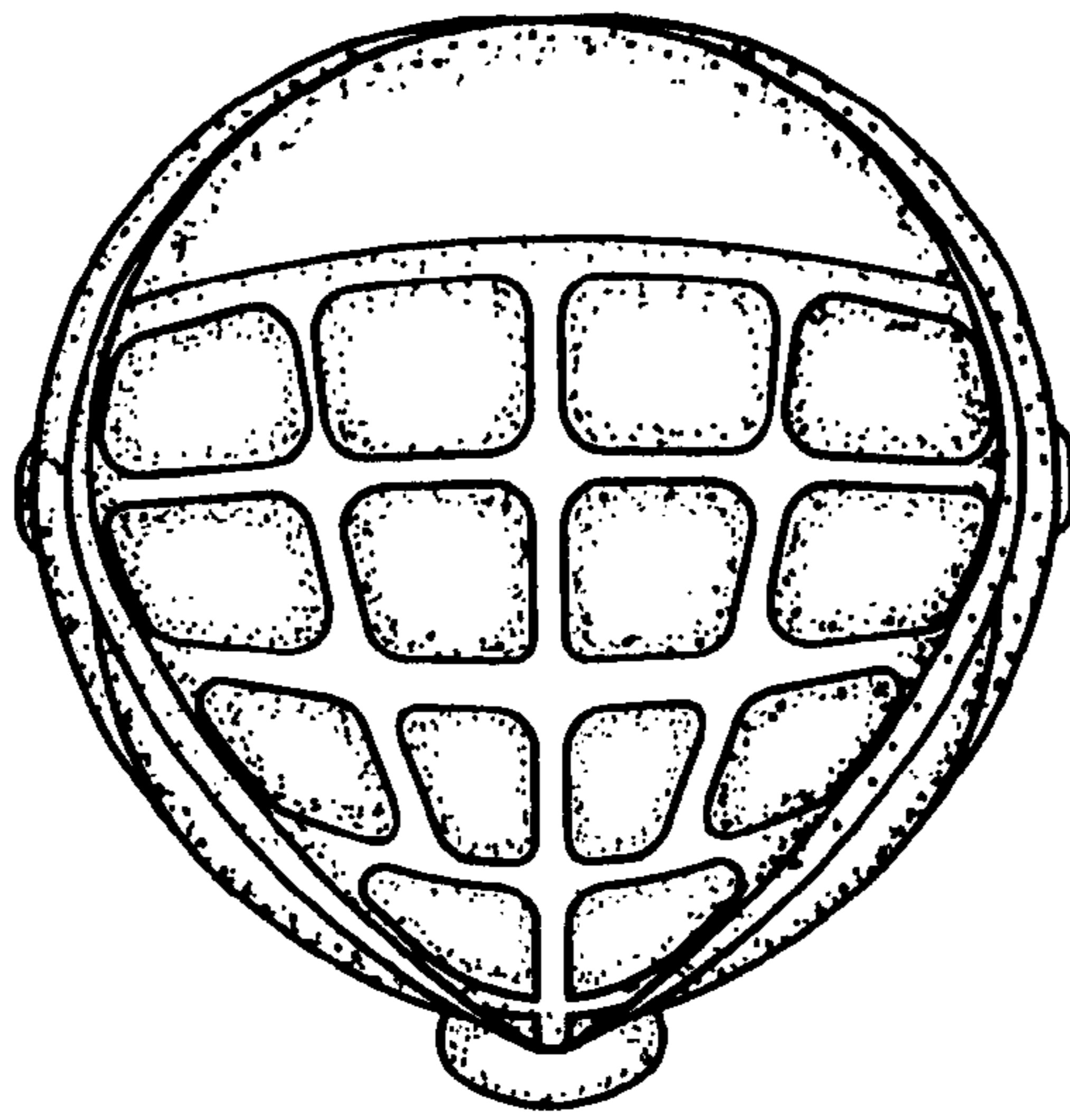


Fig.6

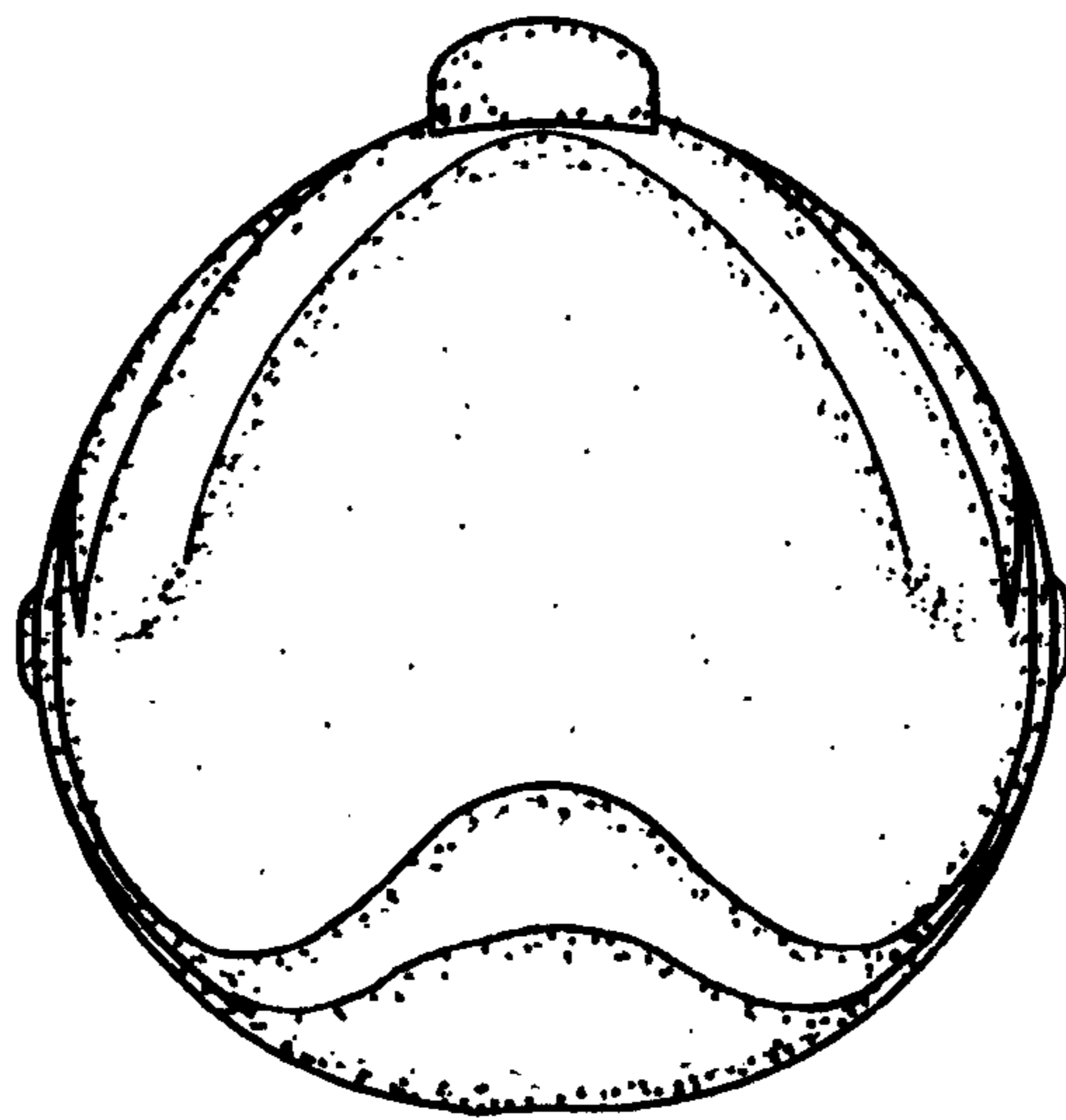


Fig.7